

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|---------|---------------------------|---|------------------|---------|------------------|
| L2 | 58292 | "sih.sub.4" "o.sub.4" | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:22 |
| L3 | 0 | "sih.sub.4" adj "o.sub.4" | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:23 |
| L4 | 1999164 | si(oh) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:24 |
| L5 | 1999164 | si(oh)4 | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:25 |
| L6 | 19 | "6268282" | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:34 |
| L7 | 18 | "6121133" | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:34 |

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|-----|-------|--|---|----|----|---------------------|
| L8 | 2077 | (oxygen near5 material) with (exposed unexposed exposure unexposure) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:36 |
| L9 | 49744 | 8 (energy) with (exposed unexposed exposure unexposure) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:37 |
| L10 | 227 | 8 and (energy) with (exposed unexposed exposure unexposure) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:37 |
| L11 | 99 | 10 and (substrate) with (exposed unexposed exposure unexposure) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:37 |
| S1 | 880 | ""sih.sub.4"" adj ""n.sub.2"" adj o | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/11 12:49 |
| S2 | 406 | si adj ""o.sub.2"" | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/11 12:49 |

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|---|------------------|---------|------------------|
| L12 | 11 | energy and (substrate with (exposed unexposed exposure unexposure)) with ((oxygen 'o2') near4 material).clm. | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 08:12 |

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|----|-----|---|---|----|----|---------------------|
| S3 | 130 | "sih.sub.4" adj "n.sub.2" adj o with (si adj "o.sub.2" silicon adj oxide) | US-PGPU B; USPAT; EPO; JPO; DERWEN T; IBM_TDB | OR | ON | 2005/07/12 07:21 |
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